



Welcome Note from Conference Co-Chair

Welcome Message:

Dear colleagues and friends,

We are delighted to invite you to join the “**International Nanotechnology and Nanoscience Conference**” Holding such an invaluable academic and scientific meeting provides a good opportunity for sharing ideas and experiences with the most outstanding domestic and foreign scholars to motivate students and graduates of Nanotechnology and all other related fields on their scientific path. For me it is an honor and a pleasure to welcoming you all at Chicago, USA, 23-24 September, 2019 to present your research work and experiences under scientific sessions.

OLCNC-2019 theme “*Exploring the new challenges and opportunities in Nanotechnology and Nanoscience*” to address the global challenges and opportunities in Nanotechnology.

The scientific program will follow a streamed format, allowing delegates to either attend days focused on a particular speciality or to enjoy the breadth of educational and social opportunities provided by the whole meeting.

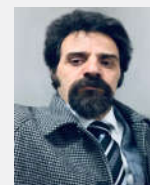
On September 23-24, 2019, Experts will share insight and inspire conversation around the importance of research, development, and technology on Nanotechnology and Nanoscience.

Speaker’s speeches of different panels, presentation of abstracts, advanced courses and workshops will form the core of **OLCNC-2019**, which will be the center of attention of all scholars, experts, and students attracted by the field of Nanotechnology.

Personally, I completed PhD from Media and Games Innovation Centre of Excellence (MaGIC-X) in University Technology Malaysia in 2013. Currently am working as a Senior Lecturer in Liverpool John Moores University. I have published numerous articles in international journals, conference proceedings and technical papers, including chapters in books.

I am looking forward to an excellent meeting with great scientists from different countries around the world and sharing new and exciting results in Nanotechnology.

I wish the conference great success.



Your’s Sincerely

Hoshang Kolivand
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